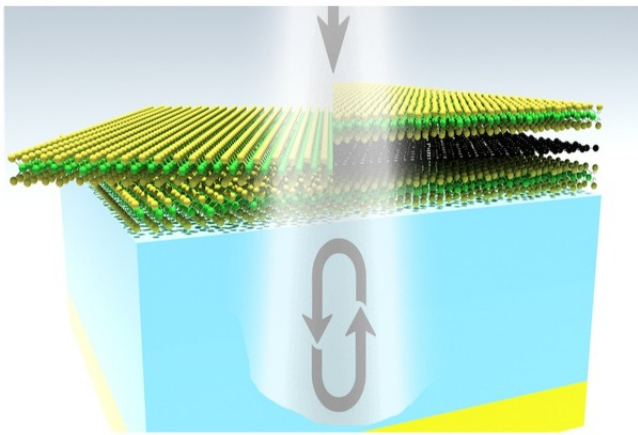




# Realization of a perfect light absorber in two-dimensional homobilayer by reducing interlayer interaction

Nanofabrication approaches for realizing perfect light absorbance in two-dimensional homobilayer materials



**IP Status:** Provisional Patent Application Filed

## Applications

- Secure optical communications
- Photodetectors
- Photovoltaics
- Stealth materials

## Technology Overview

Near-perfect light absorbers (NPLA) with absorbance of at least 99%, have a wide range of applications ranging from energy and sensing devices to stealth technologies and secure communications. Current approaches for fabricating NPLAs require complex and expensive nanofabrication approaches. Researchers at the University of Minnesota have developed multiple nanofabrication approaches that rely on straightforward fabrication approaches to significantly decrease the complexity and cost of fabricating NPLAs. This is accomplished with a simple single mirror cavity structure using a two-dimensional homobilayer with reduced interlayer interaction either by introducing a twist angle or inserting a buffer layer.

## Phase of Development

**TRL: 2-3**

Proof-of-concept

**Technology ID**

2023-007

## Category

All Technologies  
Engineering & Physical  
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Engineering & Physical  
Sciences/Nanotechnology  
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Sciences/Photonics  
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8/1/2023

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## References

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